

1026 - (12-13, 16-17)

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Jun 15, 1994

DERWENT-ACC-NO: 1995-080487

DERWENT-WEEK: 199511

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Tsepochkina

TITLE: Etching soln. for prodn. of matt surface on silicate materials and glass - contains hydrofluoric acid, sulphuric acid, glycerine, acetone@ and ethylene glycol

INVENTOR: TSEPOCHKINA YU, A

PRIORITY-DATA: 1992SU-5024817 (January 9, 1992)

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## PATENT-FAMILY:

<del>PUB-NO</del>	PUB-DATE	LANGUAGE	PAGES	MAIN-IPC
<input type="checkbox"/> <u>RU 2014302 C1</u>	June 15, 1994		002	C03C015/00

INT-CL (IPC): C03C 15/00

ABSTRACTED-PUB-NO: RU 2014302C

## BASIC-ABSTRACT:

The soln. contains (in wt.%): HF 21-22; H2SO4 51.5-53.0; glycerine 10-11.5; acetone 3.5-4.0; and ethylene glycol 11.5-12.0.

USE - Forms matt surfaces on silicate materials and glasses.

ADVANTAGE - Uniformity of treatment is improved.

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